

Title (en)
POLISHING COMPOSITION

Title (de)
POLITUR

Title (fr)
COMPOSITION DE POLISSAGE

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Application
EP 02797709 A 20020903

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• US 31796201 P 20010910

Abstract (en)
[origin: WO03020839A1] A polishing composition of abrasive grains, a phosphorus-containing inorganic acid or salt thereof and another inorganic acid or salt thereof contained in an aqueous medium is used for the polishing of magnetic disk substrates or the like.

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C09G 1/02

IPC 8 full level
C09G 1/02 (2006.01)

CPC (source: EP US)
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